



DEPARTMENT OF
INFORMATION
ENGINEERING
UNIVERSITY OF PADOVA



Scuola Nazionale di Legnaro
29/3/2007

Single Event Effects: Introduction

Alessandro Paccagnella

Dipartimento di Ingegneria dell'Informazione
Università di Padova

alessandro.paccagnella@unipd.it

- Introduction and definitions
- Classification of SEE
- Charge generation by an ionizing particle in Si (and SiO_2)
 - Collection mechanisms
 - Evolution with Moore's law
- Single Event Effects
 - Sources
 - Testing methods
- Summary

- **Single Event Effect (SEE)**: perturbation of the behavior of electronic (optoelectronic) devices, circuits and/or systems produced by a single ionizing particle
- “Timely testing avoids cosmic ray damage to critical auto electronics”, *John Wood and Earl Caustin, MOSAID Systems, 15/6/2006*
- “Cosmic rays damage automotive electronics”, *Martin Mason, Actel Corporation, 31/5/2006*
- “Alpine lab enters rarified air of soft-error test”, *Junko Yoshida, 25/9/2006*

AUTOMOTIVE | 
DesignLine

AUTOMOTIVE | 
DesignLine

EETIMES ^{ONLINE}

- If (some of) the charge generated by a **single high LET particle** is collected by a **sensitive node** of the device/circuit, and this charge is larger than the **critical charge** required to start an anomalous behavior, an **effect** (**Single Event Effect**) may be seen, affecting the electrical performance of the device/circuit:
 - **Soft errors**
 - **Hard (destructive) errors**

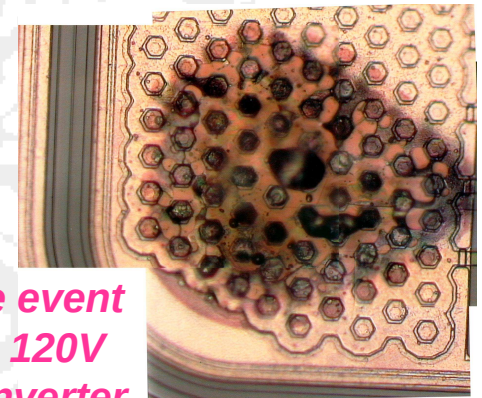
● Non-destructive (soft errors):

- Single Event Transient (SET)
- Single Event Upset (SEU)
 - Single Bit Upset (SBU)
 - Multiple Bit Upset (MBU)
- Single Event Functional Interruption (SEFI)
- Single Event Latchup (SEL or SELU)... *may be also destructive*

● Destructive (hard errors):

- Single Event Burnout (SEB)
- Single Event Gate Rupture (SEGR)
- Stuck Bits

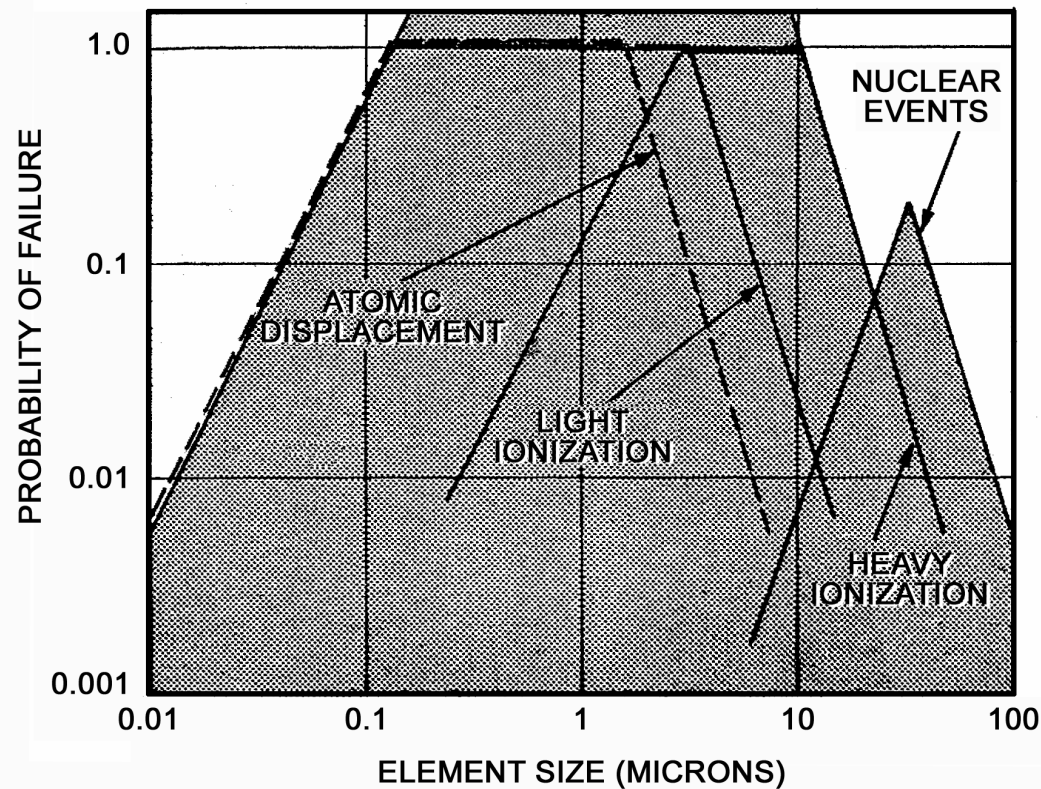
• Power devices do not follow down-scaling dimensions and voltages: they exhibit larger sensitivity to neutron-induced effects, even at sea level



*Destructive event
in a COTS 120V
DC-DC Converter*

K. LaBel, EWRHE 2004

Early warning of SEE's at sea level



J.T. Wallmark and S.M. Marcus, Proc IRE, 1962



First reported reliability effect (May & Woods, Intel, 1979) due to alpha particles in DRAMs from natural radioactive pollutants in circuit packaging

- *Societal needs for more reliable electronics*
- Reliability in advanced ICs is improving down to some **10-100 FIT**
- Electronics is now introduced in **Active Security**, especially visible in everyday vehicles (Airplanes, Automotives, Railways,...)
- **Avionic and space industry** has a long standing tradition of radiation testing, especially Single Event Effects
- More recently the SEE issue has been seriously investigated for its reliability implications even at sea level in everyday life by:
 - Semiconductor *companies*: IBM (since '80s), Intel, STMicroelectronics, TI, Infineon, Cypress, Xilinx,..., but few SEE comprehensive data from companies are available in open literature
 - Semiconductor IC *customers*: even less prone to show their interest, basically no data available
- SEE at sea level is dominated by **Soft Errors (SE)** leading to the **Soft Error Rate (SER)** figure of merit; if not properly mitigated, SER may reach **10^5 FIT**

“Soft errors have become a huge concern in advanced computer chips because, uncorrected, they produce a failure rate that is higher than all the other reliability mechanisms combined!”

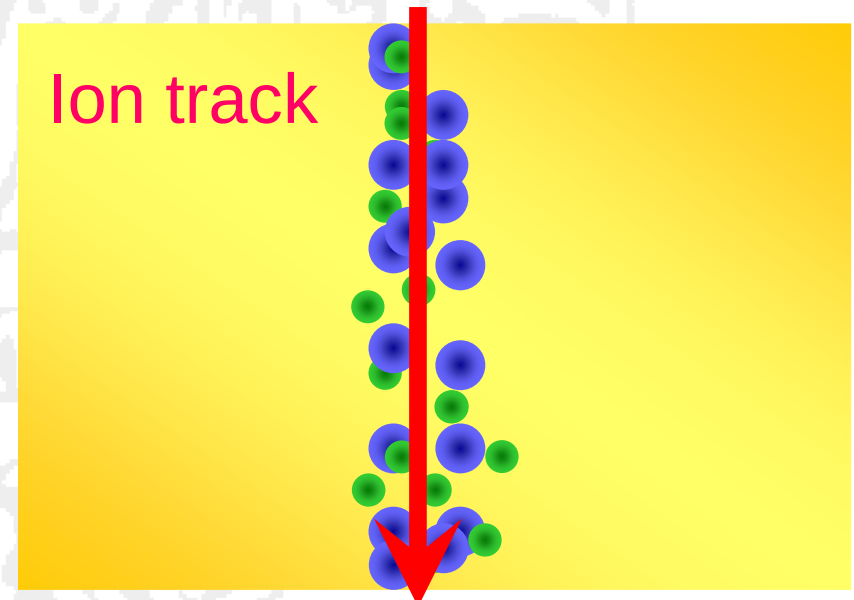
R. Baumann, IEEE-TDMR, 2005

“Since chip SER is viewed by many as a legal liability (selling something that you know may fail), the public literature in this field is sparse and always makes management nervous”

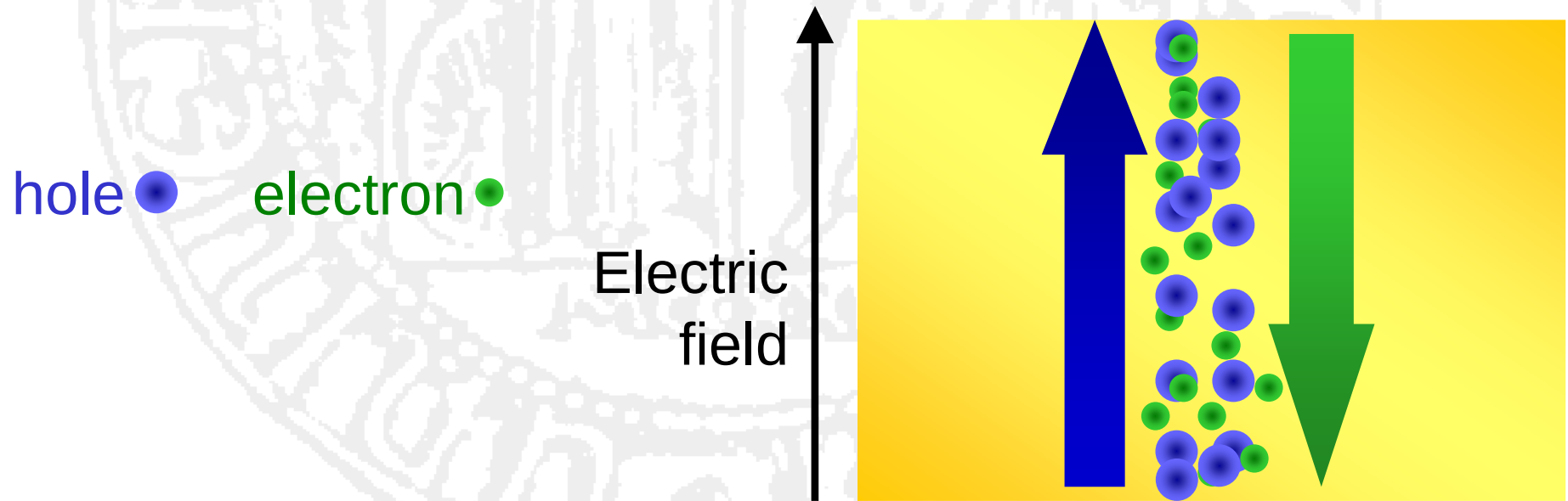
J. Ziegler and H. Puchner, “SER-History, Trends and Challenges”, Cypress Semiconductors, 2004

- An ionizing particle generates a (dense) track of electron-hole pairs in semiconductors (**Silicon**) and dielectrics (**SiO₂**)
- The number of generated carriers is proportional to the particle **Linear Energy Transfer (LET)** coefficient (MeVcm²/mg), i.e., the ionizing energy loss/unit path length (Energy / e-h pair: **3.6 eV in Si**, **17 eV in SiO₂**)
- Dosimetry: 1 rad = 100 erg/g
1 Gy = 1 J/kg = 100 rad

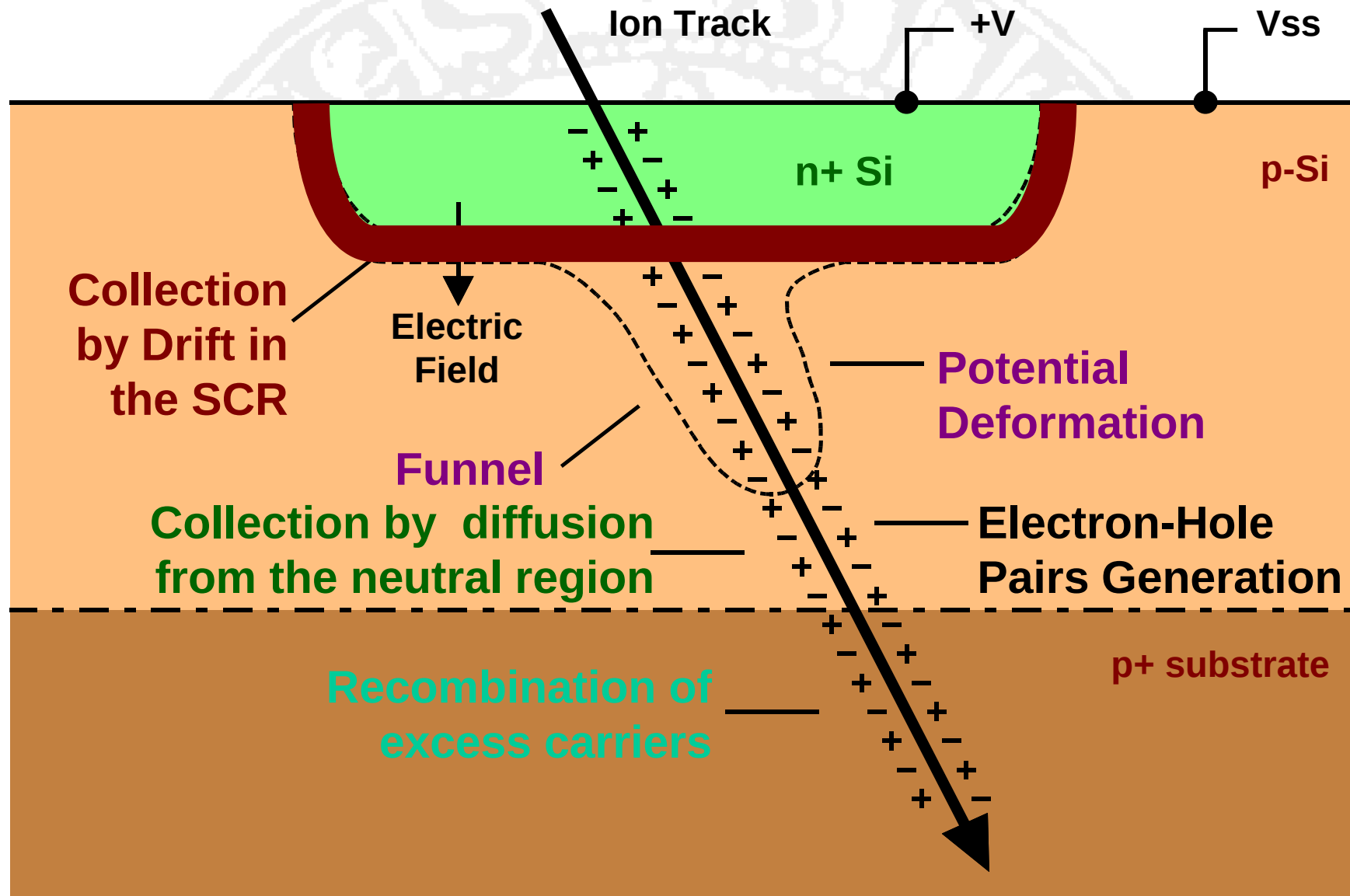
hole ●
electron ●



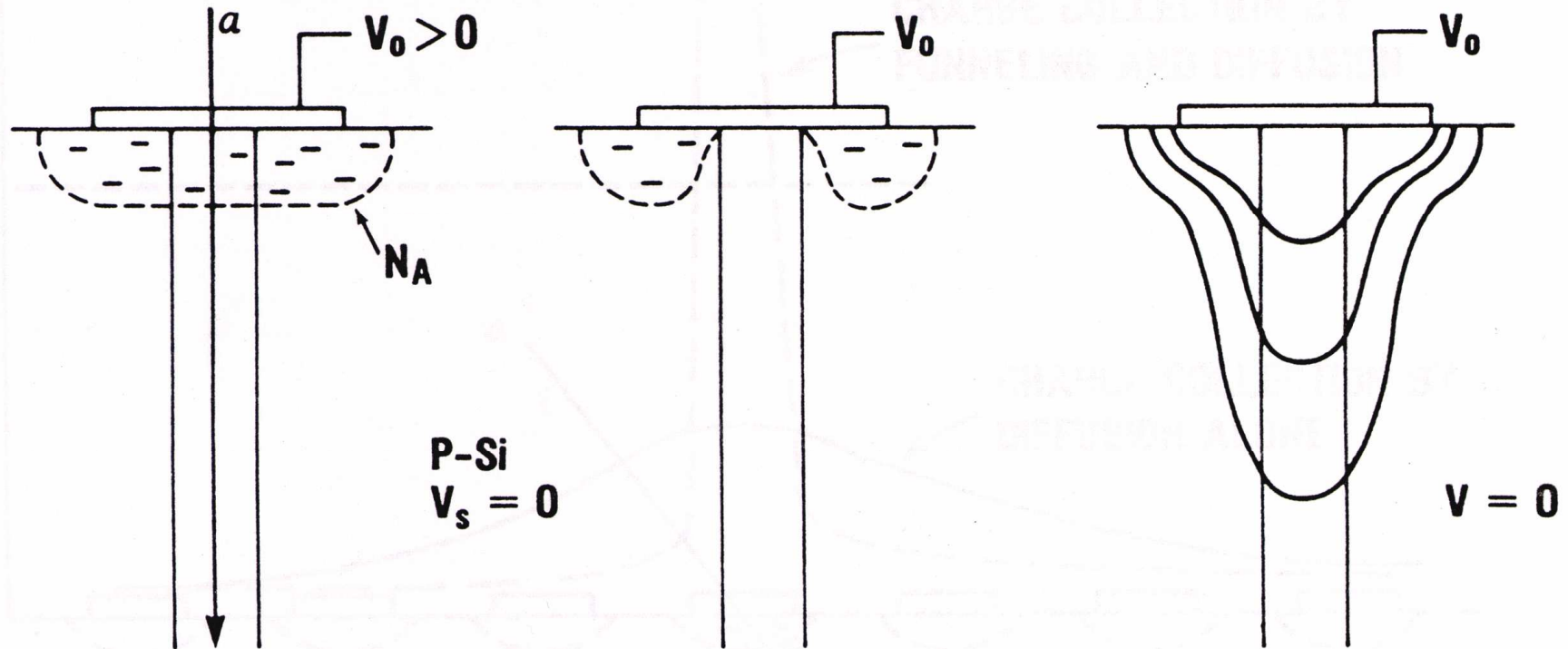
- Under an external electric field the two columns of carriers recombine and drift: many electrons and holes survive in Si, fewer in SiO_2
- Eventually, a net negative/positive charge can be collected at sensitive nodes: if this charge exceeds a threshold value (**critical charge**) an event may be observed affecting the circuit



Charge collection in a reverse biased p-n junction



- Funneling on a Schottky diode

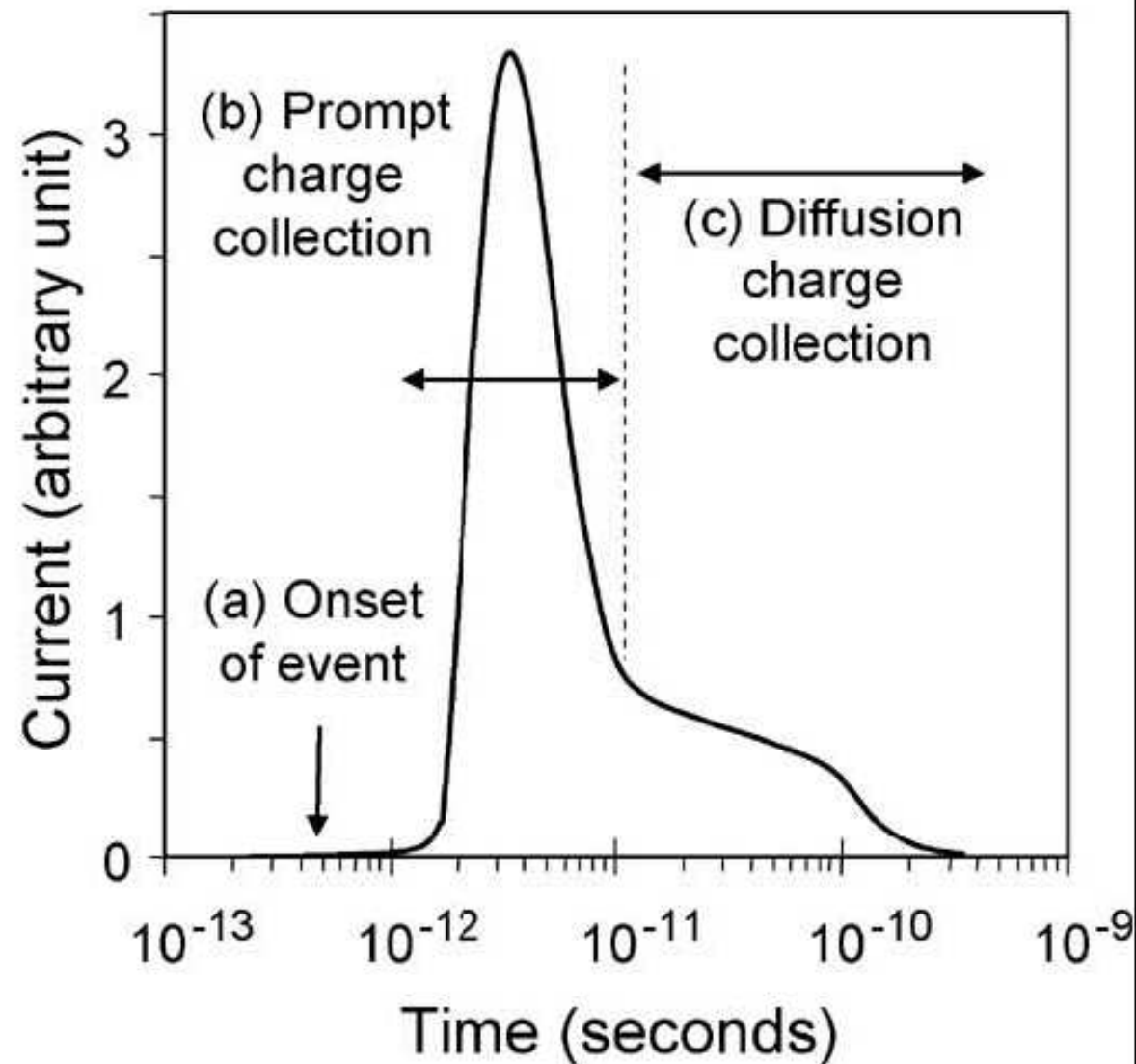


(a) a - PARTICLE STRIKE
($t = 0$)
 $n = P \gg N_A$

(b) JUNCTION DEPLETION
LAYER NEUTRALIZED
($t > 0$)

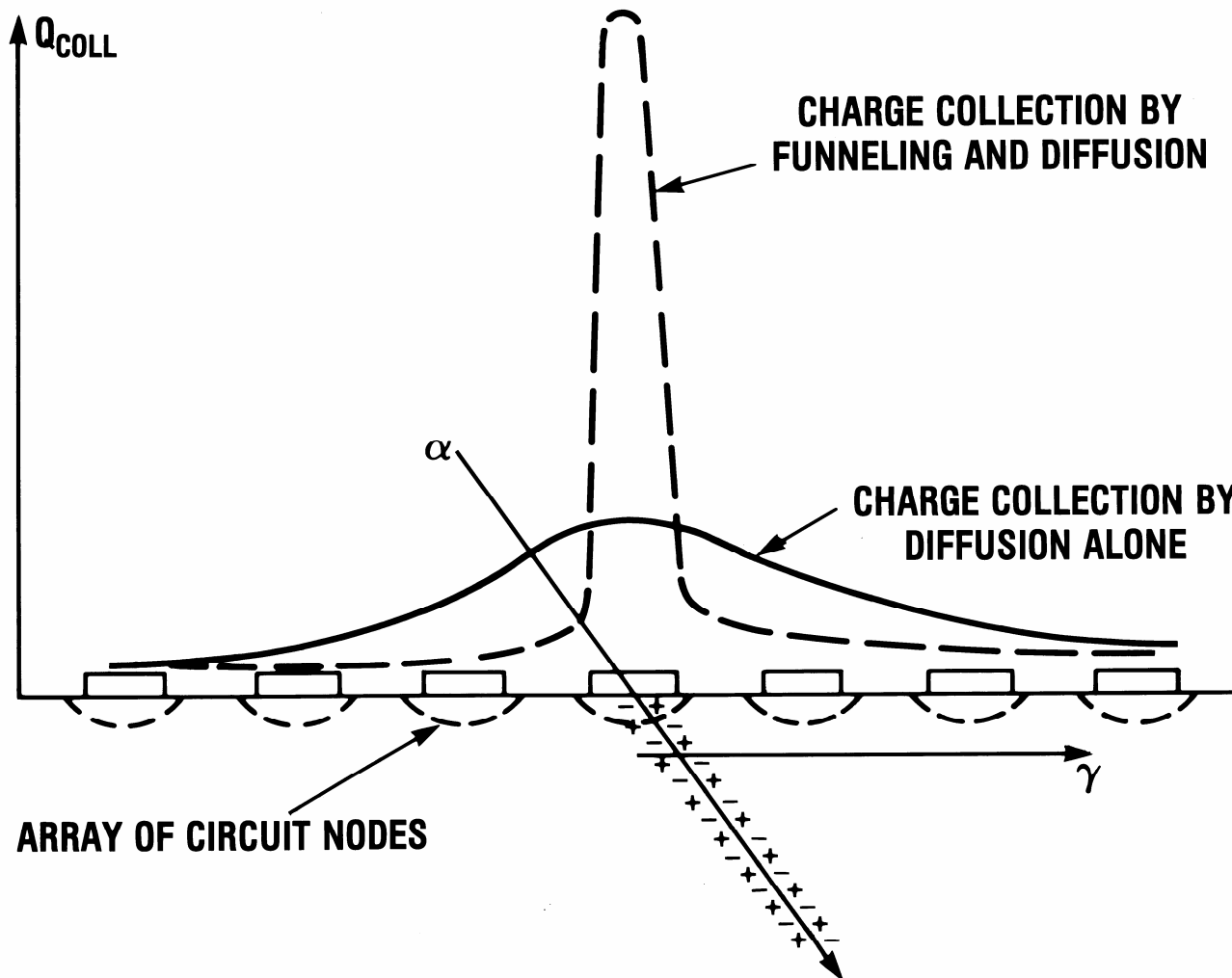
(c) EQUIPOTENTIAL LINES
EXTENDED DOWN
ALONG TRACK

F.B. McLean and T.R. Oldham, IEEE-TNS29, 1982



R. Baumann, IEEE-TDMR, 2005

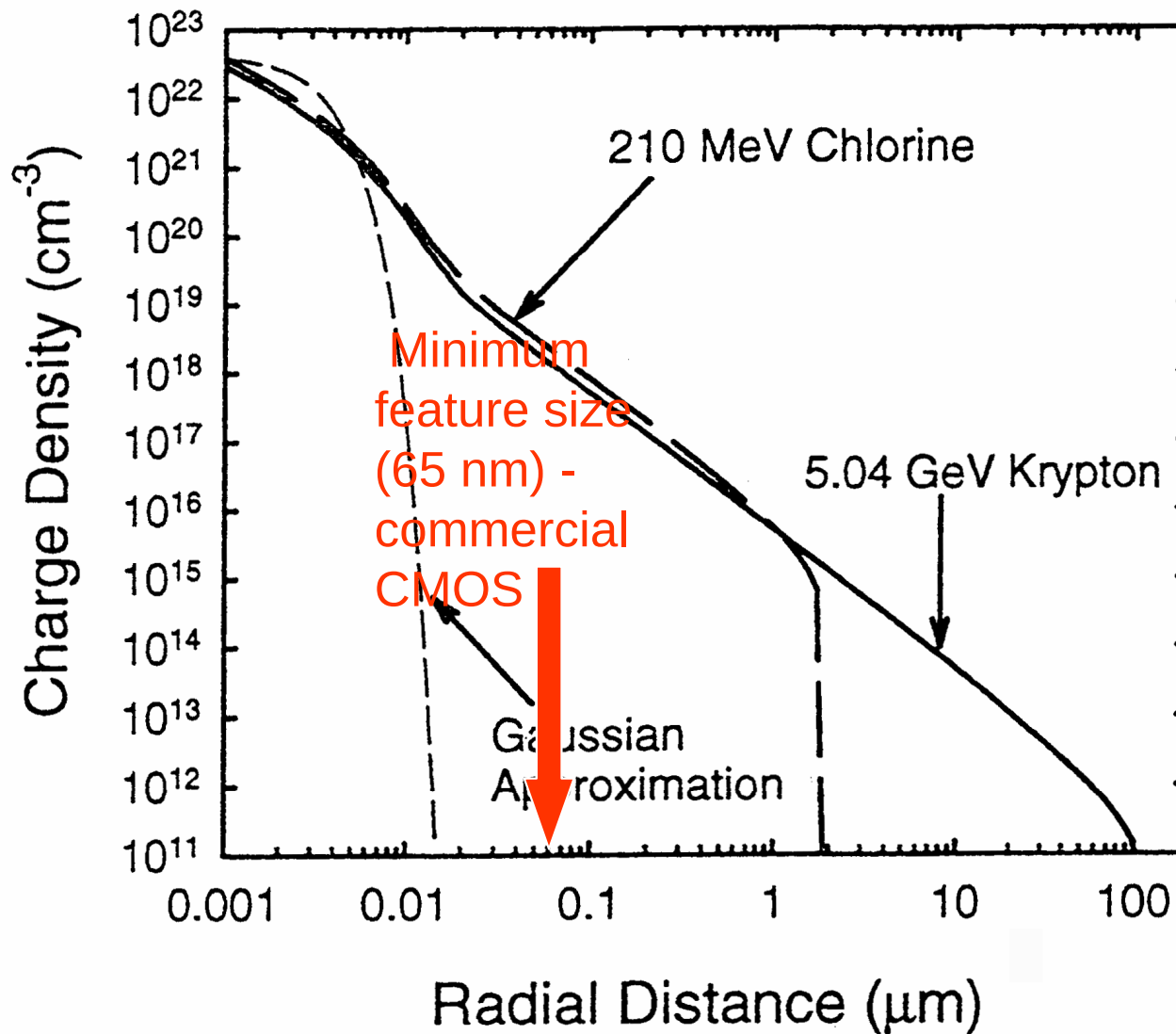
Charge collection across circuits



- “Traditional” view of charge collection in Si circuits fabricated with relaxed CMOS technologies
- Only particles at low impact angles may affect different devices, if diffusion charge collection is excluded

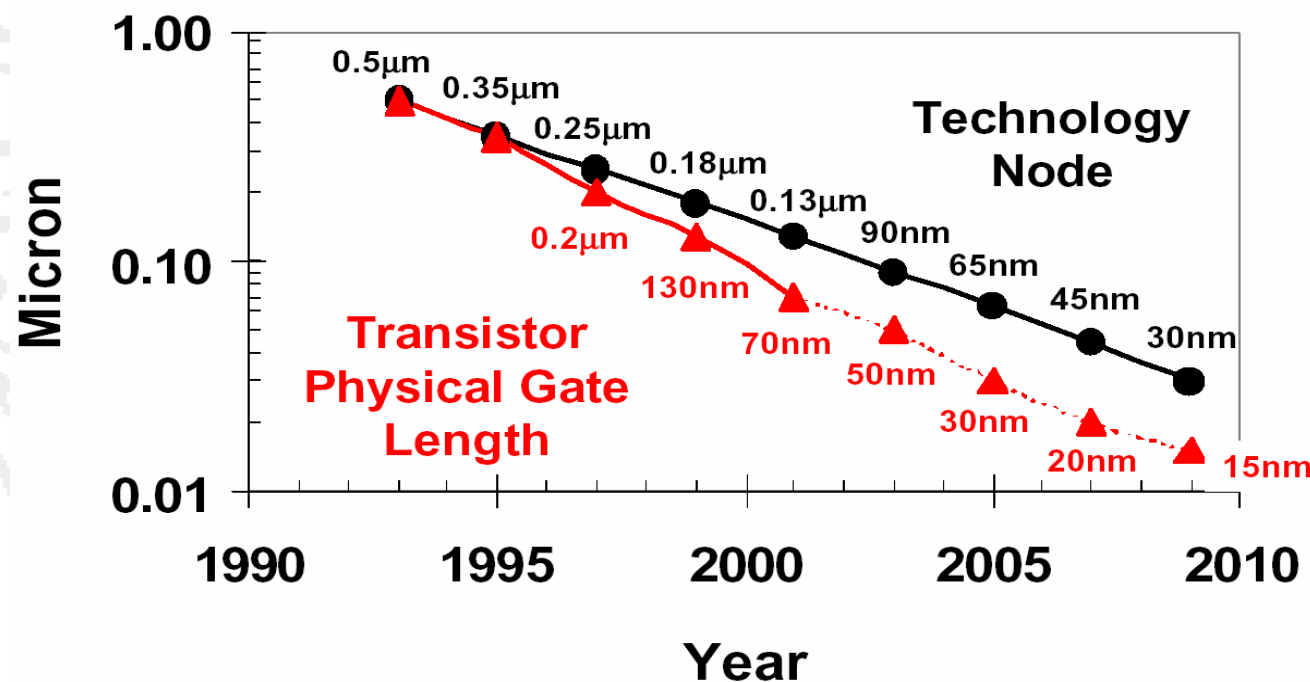
T. Oldham, NSREC Short Course, 2003

Calculated e-h track structure in Si

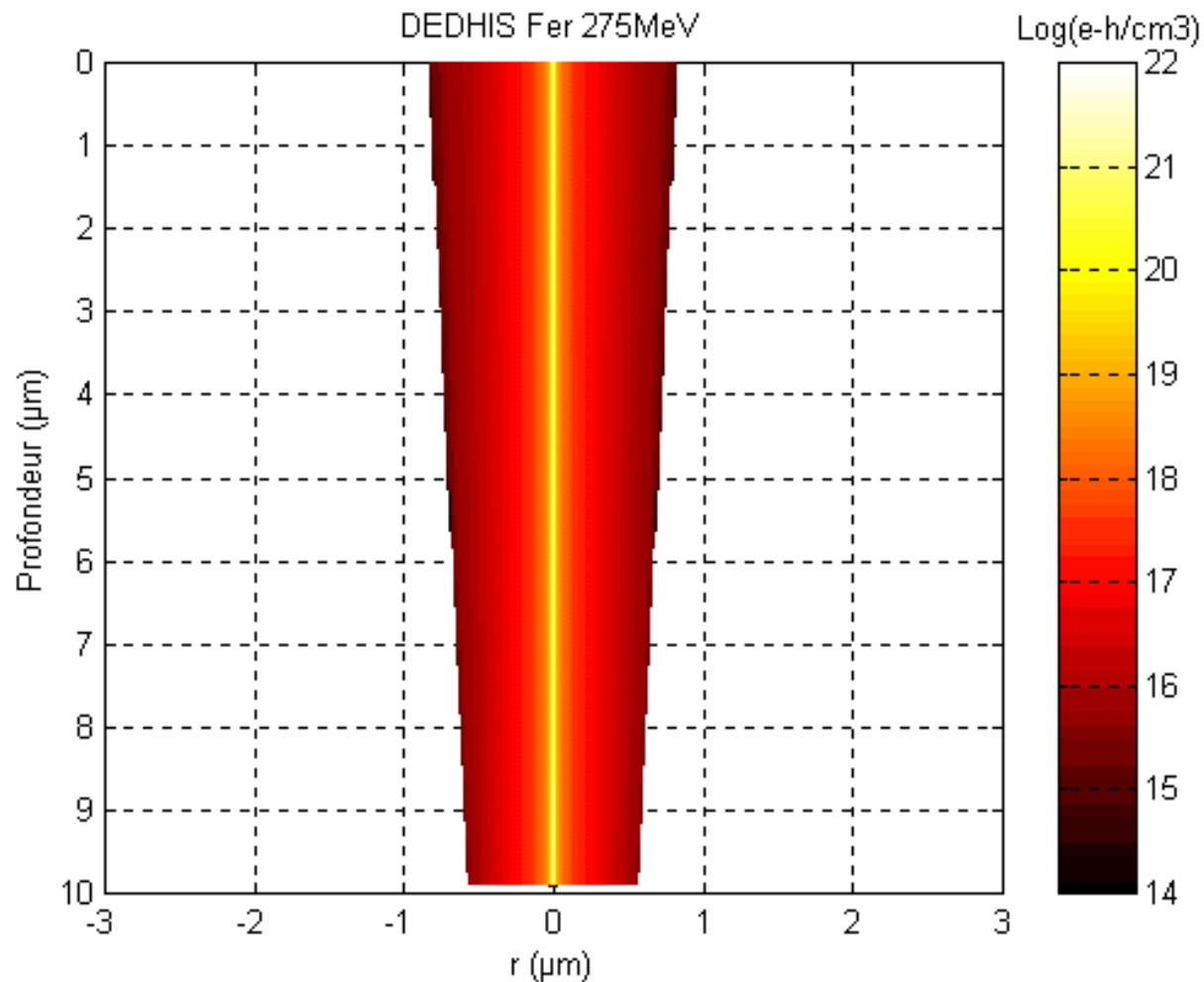


P. Dodd, et al., IEEE-TNS45, 1998

Moore's law is (self-)validated by reducing the device dimension over the years, by scaling down the **minimum feature size** of the CMOS **technology node**



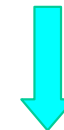
Source: INTEL



Fe ions 275 MeV
LET=24 MeVcm²/mg

LET metrics in Si:

1 MeVcm²/mg



$6.4 \cdot 10^4$ e-h pairs/ μm



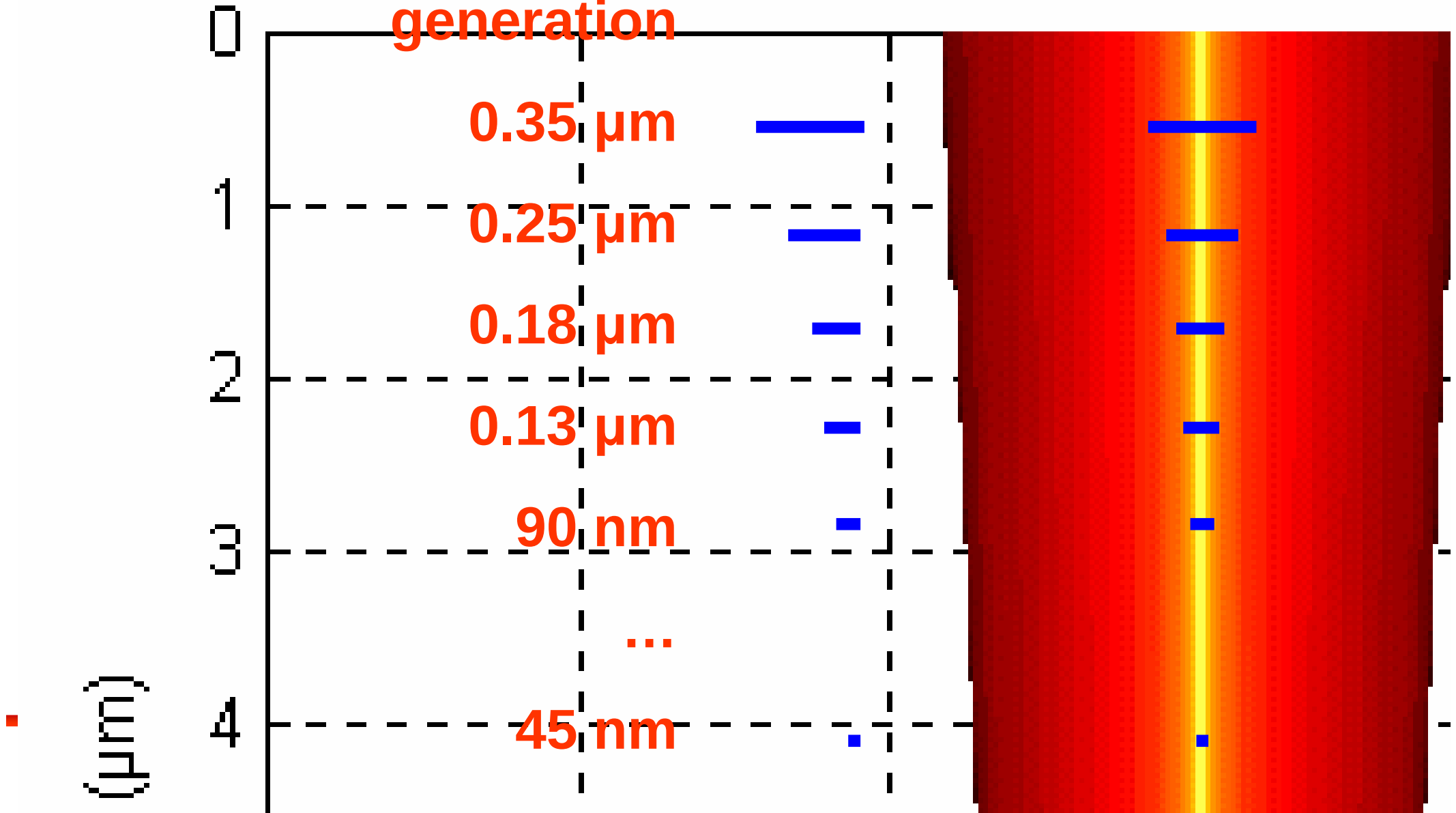
10 fC/ μm

Electron-Hole density (cm⁻³)

P. Foulliat, EWRHE 2004

CMOS
generation

DEDHIS Fer 275Me



• Space applications:

- **High-energy heavy ions**

- Long range in Si, large LET, direct interaction

- **High-energy protons** (trapped, solar, cosmic)

- Direct / Indirect interaction through nuclear reactions

• Terrestrial and avionic applications:

- **High energy neutrons** (cosmic ray byproducts)

- Indirect interaction through nuclear reactions

- **Low energy neutrons** (thermal)

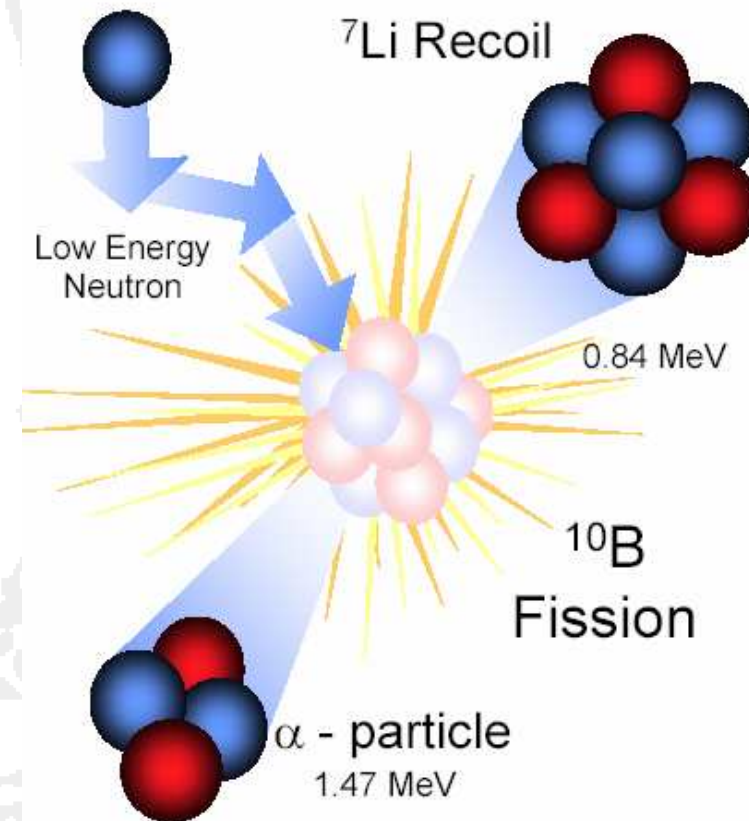
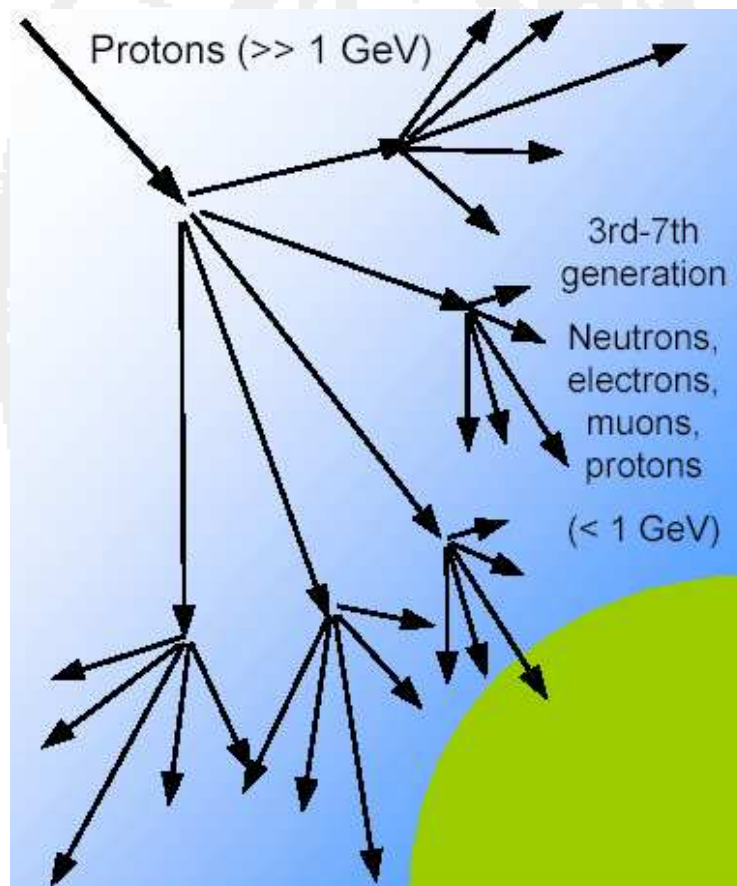
- Indirect interaction via ^{10}B nuclear reaction

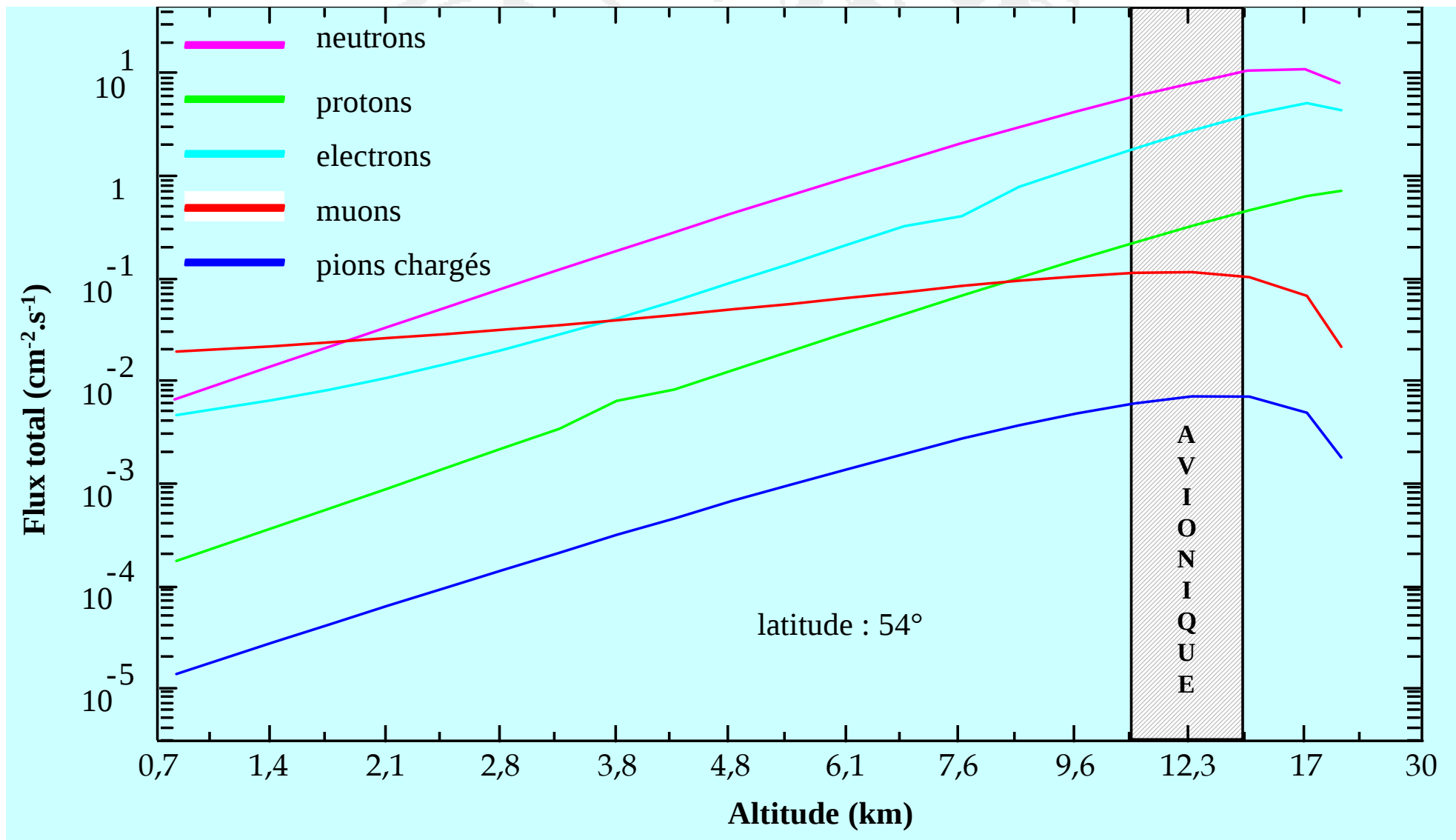
- **Alpha particles** from radioactive decay of contaminants (from U, Th decay chains) in the chip/package/solder

- Short range in Si, small LET, direct interaction

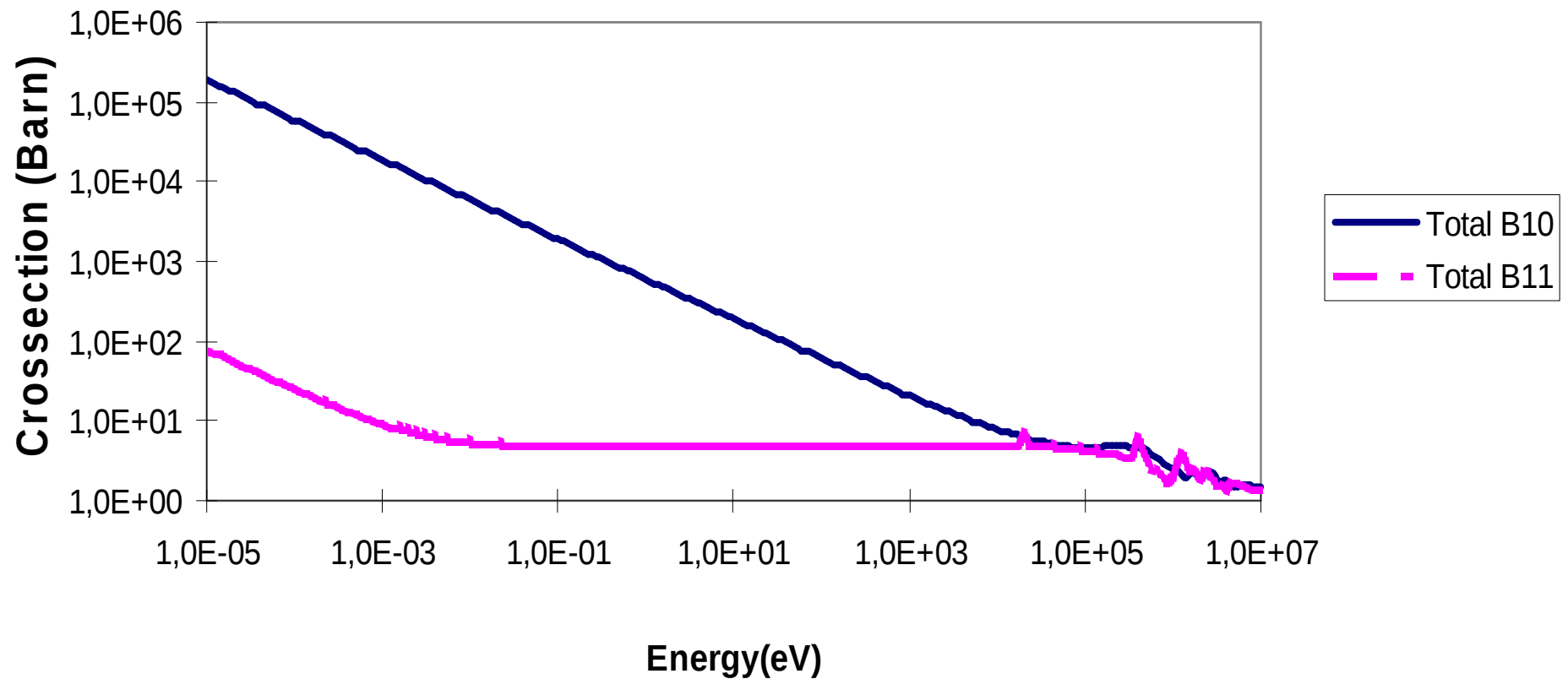
Single Event Effects even at sea level

- High energy neutrons
- Low energy neutrons





Comparison Between Boron 10 and Boron11



Material	Emission rate ($\alpha/\text{cm}^2\text{-hr}$)
Bare Si	0.00020
Plastic (epoxy)	0.00080
Ceramic lid A	0.15
Ceramic lid B	3.10
Ceramic DIP A	0.02320
Ceramic Dip B	0.03230
Ceramic Dip C	0.02610
Plastic DIP A	0.00109
Plastic DIP B	0.00124

Industrial
goal: 10^{-3}
 $\text{Alpha}/\text{cm}^2\text{h}$
as tradeoff
between
cost and
purity

The severity of the effect on the device/circuit depends on:

- pulse/charge intensity
- type of effect
- system criticality

Single Event Effects in devices/circuits can be **mitigated** by using different strategies at different levels. For instance:

- **circuit level**, by using specific technologies or processes for fabrication (such as epi-CMOS, SOI, additional capacitors in SRAM, or rad-hardened electronic components)
- **design level**, by using *ad hoc* logic structures aiming to SEE immunity (such as SEE immune latches)
- **system level**, by modifying the software and/or the hardware (such as triple redundancy)

- SEE tests are performed to evaluate the expected error / failure rate of the device/system in the specific operating environment (Space, HEP, Avionic, Sea level,...) by using:
 - Ion beams from accelerators
 - Neutron beams
 - Alpha sources
 - Lasers
 - A large number of devices operating under low intensity radiation (*unaccelerated tests: the Rosetta experiment*)
- The SEE sensitivity of each SEE type (SEU, SEL, SEB, ...) in any particular device is evaluated by measuring the corresponding **cross section** vs **LET**:
 - **Cross section** : $\sigma(\text{LET}) = \# \text{ Events} / \text{particle fluence (cm}^2\text{)}$
 - The error rates in operating condition is derived from cross sections and the features (nature of particles, corresponding fluxes, mission duration) of the actual environment
 - Error rate = # errors / device day

- **LET_{th}** is the minimum (**threshold**) LET to cause the specific SEE
- The saturation cross section **σ_{sat}** is approached at high LET values
- The **σ(LET)** curve is obtained by measuring the cross section at a few LET values and fitting data with a Weibull curve

LET_{th}

<i>Device Threshold</i>	<i>Environment to be Assessed</i>
LET _{th} < 10 MeV*cm ² /mg	Cosmic Ray, Trapped Protons, Solar Flare
LET _{th} = 10-100 MeV*cm ² /mg	Cosmic Ray
LET _{th} > 100 MeV*cm ² /mg	No analysis required

R. Velazco, EWRHE 2004

The **cross section** (σ) for Single Event Effects is $\sigma = N_{\text{SEE}} / \Phi$

N_{SEE} : number (counts) of SEE observed

Φ : uniform fluence over some fiducial area

practical flux set by dead-time of DUT (typical few $10 \div 10^4$ ions $\text{cm}^{-2}\text{s}^{-1}$)

- Statistical Error improves with Fluence
- however **Fluence Limited by Total Dose**

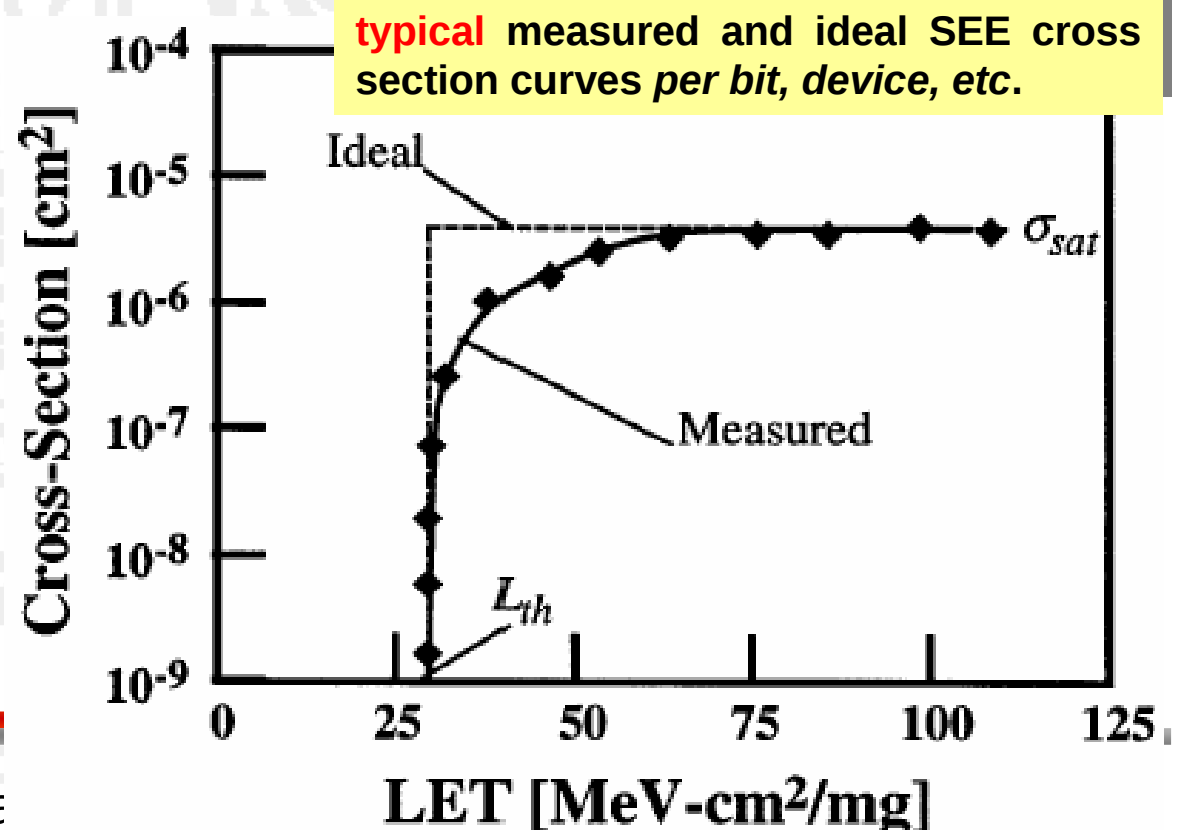
WEIBULL FIT of threshold curve

$$\sigma = \sigma_{\text{sat}} \times \{1 - \exp[-(L - L_{\text{th}})/W]^s\}$$

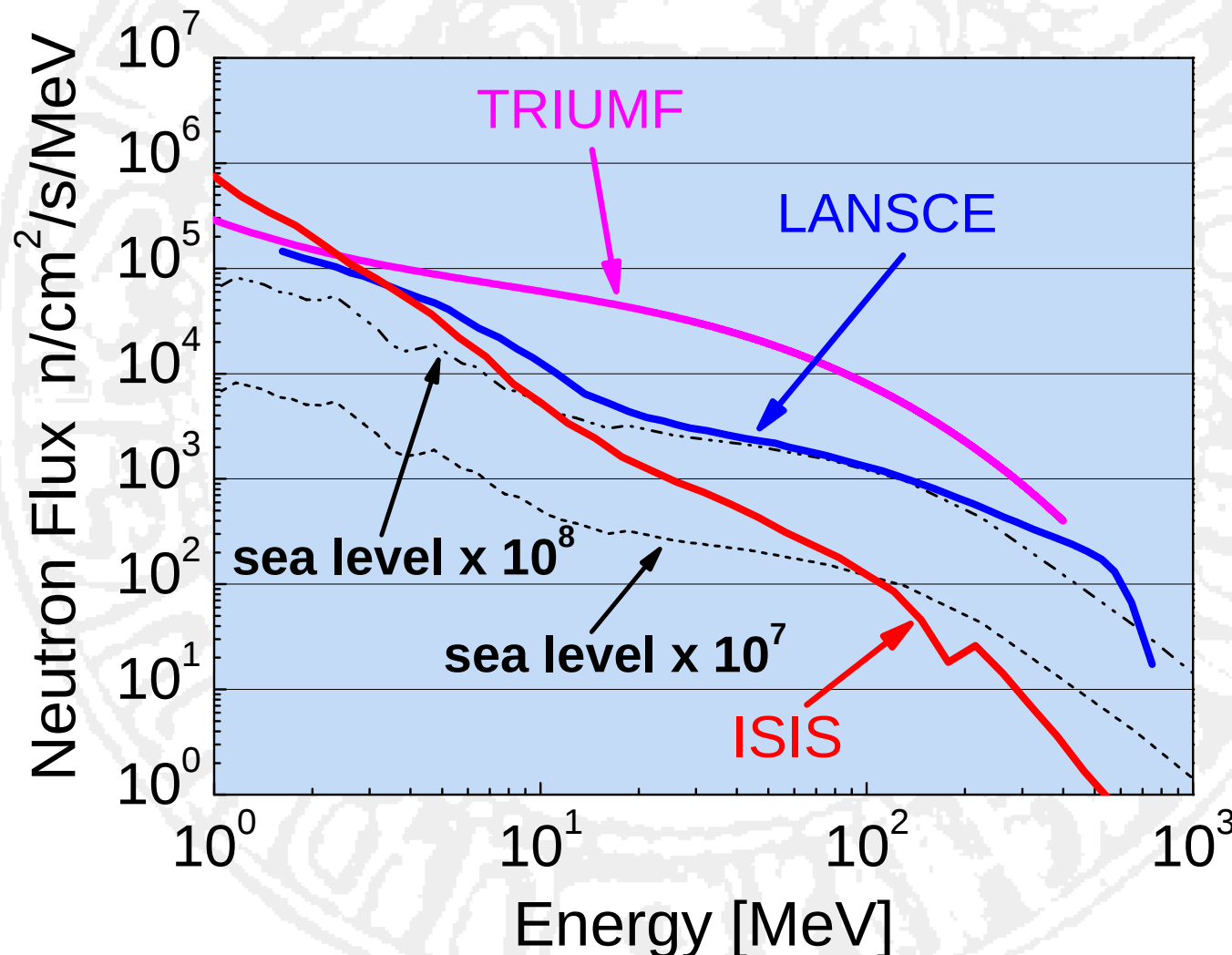
σ_{sat} : saturation value

L_{th} : threshold LET value

W and s are fitting parameters



The terrestrial n spectrum features a $\sim 1/E^\alpha$ characteristic ($\alpha > 1$): few laboratories worldwide may provide a flux similar to the terrestrial with an **acceleration factor** between 10^7 and 10^8



- Single event effects are produced by collecting the charge generated (usually in the semiconductor) by a single ionizing particle: charge > **critical charge**
- The e-h track may include more than one active device (e.g., MOSFET)
- Different SEE's may occur depending on the device type, being either **soft** or **hard** in nature
- Each SEE for a specific device is characterized by its **cross section** and **threshold LET**
- SEE's are expected not only in radiation harsh environments but also at sea level